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|               | <sup>1</sup> Fudan University, China; <sup>2</sup> Ghent University, Belgium  |     |
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|        | <sup>1</sup> University College Cork, Ireland; <sup>2</sup> Grenoble INP Phelma, Minatec, 3 Parvis Louis Néel, 38016 Grenoble Cedex 1, France; <sup>3</sup> University College Cork, Ireland |     |
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|        | <sup>1</sup> Sardar Patel Institute of Technology, India; <sup>2</sup> Indian Institute of Technology, India   |     |
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|        | <sup>1</sup> Institute of Microelectronics; <sup>2</sup> School of Mathematical Sciences, LMAM and CAPT, Peking University, China  |     |
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|        | <sup>1</sup> National Tsing Hua University, Taiwan, China; <sup>2</sup> Tung Hai University, Taiwan, China; <sup>3</sup> Macronix International Co. Ltd., Taiwan, China                      |     |
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|                  | <sup>1</sup> IBM T. J. Watson Research Center, USA; <sup>2</sup> IBM Systems and Technology Group, USA;<br><sup>3</sup> IBM Almaden Research Center, USA; <sup>4</sup> IBM Systems and Technology Group, USA;<br><sup>5</sup> IBM Systems and Technology Group, USA.  |      |
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|               | <sup>1</sup> Fudan University, China; <sup>2</sup> Ghent University, Belgium  |      |
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|               | <sup>1</sup> National University of Singapore (NUS), Singapore; <sup>2</sup> Globalfoundries Singapore Pte Ltd, Singapore.                          |      |
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|               | <sup>1</sup> Department of Material Science; <sup>2</sup> State Key Laboratory of ASIC and System, Department of Microelectronics, Fudan University, China |      |
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|               | General Research Institute for Nonferrous Metals, People's Republic of China   |      |
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|               | <sup>1</sup> Chang Gung University, Taiwan, China; <sup>2</sup> Chi Nan University   |      |
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|               | <sup>a</sup> Samsung Electronics Co. Ltd, Korea; <sup>b</sup> Sungkyunkwan University, KOREA   |      |

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|                  | <sup>1</sup> Tohoku University, Japan  |      |
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|                  | Dept. of Electrical Engineering and Center for Integrated Systems, Stanford University, USA; <sup>#</sup> Dept. of Chemistry and Center for Integrated Systems, Stanford University, USA |      |
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|                  | National Tsing Hua University, Taiwan, China; <sup>1</sup> Industrial Technology Research Institute, Hsinchu, Taiwan, China  |      |
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|                  | Emerging Central Lab. Macronix International Co., Ltd., Taiwan, China  |      |
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|                  | National Chiao Tung University, Taiwan, China  |      |
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|               | <sup>1</sup> IBM-MagIC MRAM Alliance, T.J. Watson Research Center, USA   |      |
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|               | Ma Ya-qi, Zheng Jian-bin, Zhang Zhao-yong, Yao Qi-shuang, Wang Yong, Zhang Yi-ping<br>Aicestar Technology Corp., China  |      |
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|               | Laidong Wang <sup>1,2</sup> , Yiqun Wei <sup>1,2</sup> , Wei Wang <sup>1,2</sup> , Ling Wang <sup>1,2</sup> , Xinnan Lin <sup>1,2</sup> , Jin He <sup>1,2</sup><br><sup>1</sup> Peking University Shenzhen Graduate School, China; <sup>2</sup> PKU HKUST Shenzhen Institute, China   |      |

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| <b>P07_08</b> | <b>SiNx-doped Sb2Te3 films for phase change memory</b>   | 1142 |
|               | Gang Guo, Jie Feng, Yin Zhang,   |      |
|               | Shanghai Jiao Tong University, China   |      |
| <b>P07_09</b> | <b>Pulse Voltage Dependent Resistive Switching Behaviors of HfO2-Based RRAM</b>  | 1145 |
|               | Bin Gao, Bing Chen, Yuansha Chen, Lifeng Liu, Xiaoyan Liu, Ruqi Han, and Jinfeng Kang  |      |
|               | Peking University & Key Laboratory of Microelectronic Devices and Circuits, Ministry of Education, China   |      |
| <b>P07_10</b> | <b>A Low-cost Memristor Based on Titanium Oxide</b>  | 1148 |
|               | Ying-Tao Li <sup>1,2</sup> , Shi-Bing Long <sup>1</sup> , Hang-Bing Lv <sup>1</sup> , Qi Liu <sup>1</sup> , Qin Wang <sup>1</sup> , Yan Wang <sup>1,2</sup> , Sen Zhang <sup>1</sup> , Wen-Tai Lian <sup>1</sup> , Su Liu <sup>2</sup> , and Ming Liu <sup>1</sup> |      |
|               | <sup>1</sup> Chinese Academy of Sciences, China; <sup>2</sup> Lanzhou University, China  |      |
| <b>P07_11</b> | <b>Improved Performance of Si-NC Memory Using a Novel Two-Step Program Scheme</b>  | 1151 |
|               | Xiaonan Yang <sup>1,2</sup> , Manhong Zhang <sup>1</sup> , Yong Wang <sup>1,2</sup> , Qin Wang <sup>1</sup> , Zongliang Huo <sup>1</sup> , Dandan Jiang <sup>1</sup> , Shibing Long <sup>1</sup> , Bo Zhang <sup>2</sup> , and Ming Liu <sup>1</sup>               |      |
|               | <sup>1</sup> Chinese Academy of Sciences, China; <sup>2</sup> Grace Semiconductor Manufacturing Corporation, China   |      |
| <b>P07_12</b> | <b>Self-consistent Simulation of PRAM with Comprehensive Physical Models</b>   | 1154 |
|               | Decheng Song, Xiaoyan Liu, Gang Du, Ruqi Han, Jinfeng Kang   |      |
|               | Peking University, China   |      |
| <b>P07_13</b> | <b>On the Bipolar and Unipolar Resistive Switching Characteristics in Ag/SiO2/Pt Memory Cells</b>  | 1157 |
|               | Lifeng Liu, Bin Gao, Bing Chen, Yuansha Chen, Yi Wang, Jinfeng Kang, Ruqi Han  |      |
|               | Peking University, China   |      |
| <b>P07_14</b> | <b>Thermally Stable TaOx-based Resistive Memory with TiN Electrode for MLC Application</b>   | 1160 |
|               | Lijie Zhang, Ru Huang, Dejin Gao, Yue Pan, Shiqiang Qin, Zhe Yu, Congyin Shi, Yangyuan Wang  |      |
|               | Peking University, China   |      |
| <b>P07_15</b> | <b>Resistive Switching Mechanism of Cu Doped ZrO2-Based RRAM</b>   | 1163 |
|               | Shi-Bing Long, Qi Liu, Hang-Bing Lv, Ying-Tao Li, Yan Wang, Sen Zhang, Wen-Tai Lian and Ming Liu   |      |
|               | Chinese Academy of Sciences, China   |      |
| <b>P07_16</b> | <b>Novel polymer resistive memory based on parylene with high compatibility and scalability</b>  | 1166 |
|               | Yu Tang, Yongbian Kuang, Wei Ding, Lijie Zhang, Poren Tang, Shiqiang Qin, Yangyuan Wang, and Ru Huang  |      |
|               | Peking University, China   |      |
| <b>P07_17</b> | <b>Improvement of Electrical Characteristics on P+ Source/Drain Ion Implantation by N2 Anneal for NAND Flash Memory</b>  | 1169 |
|               | Young-suk Kim, Hyun-mog Park, Jong-ho Park   |      |
|               | Samsung Electronics Co. Ltd, Korea   |      |

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| <b>I08_01</b>    | <b>New Functional Devices Fabricated by Bio Nano Process</b>   | 1172 |
| <b>(Invited)</b> | Yukiharu Uraoka <sup>1,3</sup> , Ichiro Yamashita <sup>1,2,3</sup>   |      |
|                  | <sup>1</sup> Nara Institute of Science and Technology; <sup>2</sup> Panasonic Electric Industrial Co., Ltd.; <sup>3</sup> CREST, Japan Science and Technology Agency   |      |
| <b>I08_02</b>    | <b>Novel Terahertz Nanodevices and Circuits</b>  | 1176 |
| <b>(Invited)</b> | Claudio Balocco <sup>1</sup> , Shahrir R. Kasjoo <sup>1</sup> , Xiaofeng Lu <sup>1</sup> , Linqing Zhang <sup>1</sup> , Yasaman Alimi <sup>1</sup> , Stephan Winnerl <sup>2</sup> , Peng Bao <sup>1</sup> , Yi Luo <sup>1</sup> , Kin Lee <sup>1</sup> and Aimin M. Song <sup>1</sup>  |      |
|                  | <sup>1</sup> University of Manchester, United Kingdom; <sup>2</sup> Forschungszentrum Dresden-Rossendorf (FZD), Germany  |      |
| <b>I08_03</b>    | <b>InGaAs and Ge MOSFETs with a common high k gate dielectric</b>  | 1180 |
| <b>(Invited)</b> | W. C. Lee <sup>1,2</sup> , T. D. Lin <sup>1</sup> , L. K. Chu <sup>1</sup> , P. Chang <sup>1</sup> , Y. C. Chang <sup>1</sup> , R. L. Chu <sup>1</sup> , H. C. Chiu <sup>1</sup> , C. A. Lin <sup>3</sup> , W. H. Chang <sup>1</sup> , T. H. Chiang <sup>1</sup> , Y. J. Lee <sup>1</sup> , M. Hong <sup>1</sup> and J. Kwo <sup>2,3</sup> |      |
|                  | <sup>1</sup> Department of Materials Science and Engineering, Natl. Tsing Hua Univ., Taiwan, China;  |      |
|                  | <sup>2</sup> Department of Physics, Natl. Tsing Hua Univ., Taiwan, China; <sup>3</sup> Natl Taiwan Univ., Taiwan, China  |      |
| <b>I08_06</b>    | <b>Carbon Based Graphene Nanoelectronics Technologies</b>  | 1192 |
| <b>(Invited)</b> | Chun-Yung Sung   |      |
|                  | IBM T.J. Watson Research Center, U.S.A.  |      |
| <b>I08_07</b>    | <b>Single-Electron Transistors fabricated by Electroless Plated Nanogap Electrodes and Chemisorbed Au Nanoparticles</b>  | 1194 |
| <b>(Invited)</b> | Yutaka Majima <sup>1,3</sup>   |      |
|                  | <sup>1</sup> Tokyo Institute of Technology, Japan; <sup>2</sup> CREST-JST, Japan; <sup>3</sup> Sunchon National University, Korea  |      |
| <b>I08_08</b>    | <b>Scaled Silicon Nanoelectromechanical (NEM) Hybrid Systems</b>   | 1198 |
| <b>(Invited)</b> | Hiroshi Mizuta <sup>1</sup> , Mario A. Garcia-Ramirez <sup>1</sup> , Faezeh. A. Hassani <sup>1</sup> , Mohammad. A. Ghiass <sup>1</sup> , Nima Kalhor <sup>1</sup> , Zakaria Moktadir <sup>1</sup> , Yoshishige Tsuchiya <sup>1</sup> , Shunichiro Sawai <sup>2</sup> , Jun Ogi <sup>2</sup> , Shunri Oda <sup>2</sup>                     |      |
|                  | <sup>1</sup> University of Southampton, UK; <sup>2</sup> Tokyo Institute of Technology, Japan  |      |
| <b>I08_09</b>    | <b>Graphene Transistors – A New Contender for Future Electronics</b>   | 1202 |
| <b>(Invited)</b> | Frank Schwierz   |      |
|                  | Technische Universität Ilmenau, Germany  |      |
| <b>I08_10</b>    | <b>Characteristics and modeling of Si-nanowire FETs</b>  | 1206 |
| <b>(Invited)</b> | Yoon-Ha Jeong <sup>1,2</sup> , Rock-Hyun Baek <sup>1</sup> , Sang-Hyun Lee <sup>1</sup> , Chang-Ki Baek <sup>3</sup> , and Dae M. Kim <sup>3</sup>   |      |
|                  | <sup>1</sup> Pohang University of Science and Technology (POSTECH), Republic of Korea; <sup>2</sup> National   |      |

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|               | Center for Nanomaterials Technology (NCNT), Republic of Korea; <sup>3</sup> Korea Institute for Advanced Study (KIAS), Korea   |      |
| <b>I08_11</b> | <b>Carbon Nanotube Nanoelectronics and Macroelectronics</b>  | 1210 |
| (Invited)     | Chongwu Zhou<br>University of Southern California, USA   |      |
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| (Invited)     | Wenjuan Zhu, Vasili Perebeinos, Deborah Neumayer, Marcus Freitag, Keith Jenkins, Yu Zhu, and Phaedon Avouris<br>IBM Thomas J. Watson Research Center, Yorktown Heights, USA  |      |
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| (Invited)     | Hiroyuki Kageshima<br>Nippon Telegraph and Telephone Corporation, Japan  |      |
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| (Invited)     | Paul K Chu<br>City University of Hong Kong, Hong Kong, China   |      |
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| (Invited)     | Fumio Koyama<br>Tokyo Institute of Technology, Japan   |      |
| <b>I08_16</b> | <b>Superlattice-Based Steep-Slope Switch</b>   | 1227 |
| (Invited)     | E. Gnani, S. Reggiani, A. Gnudi and G. Baccarani<br>University of Bologna, Italy   |      |
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| (Invited)     | Tony Low<br>Purdue University, US,   |      |
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|               | Po-Hsieh Lin, Jyi-Tsong Lin, Yu-Che Chang, Yi-Chuen Eng, and Hsuan-Hsu Chen<br>National Sun Yat-Sen University, Taiwan, China.   |      |
| <b>008_02</b> | <b>Applications of Tunneling FET in Memory Devices</b>   | 1238 |
|               | Song-Gan Zang <sup>1</sup> , Xin-Yan Liu <sup>1</sup> , Xi Lin <sup>1</sup> , Lei Liu <sup>2</sup> , Wei Liu <sup>2</sup> , David Wei Zhang <sup>1</sup> , Peng-Fei Wang <sup>1</sup> , Walter Hansch <sup>3</sup><br><sup>1</sup> Fudan University, China; <sup>2</sup> Oriental Semiconductor Co., China; <sup>3</sup> Universitaet der Bundeswehr Munich, Germany |      |
| <b>008_03</b> | <b>Impacts of Diameter-Dependent Annealing on S/D Extension Random Dopant Fluctuations in Silicon Nanowire MOSFETs</b>   | 1241 |
|               | Tao Yu, Runsheng Wang, Wei Ding, Ru Huang<br>Peking University, China  |      |
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|               | Shu-Yi Liu <sup>1</sup> , Jia-Hong Wu <sup>1</sup> , Shu-Ti Li <sup>2</sup> , Tao Chen <sup>1</sup> , Shao-Ren Deng <sup>1</sup> , Yu-Long Jiang <sup>1</sup> , Guo-Ping Ru <sup>1</sup> and Xin-Ping Qu <sup>1</sup><br><sup>1</sup> Fudan University, China; <sup>2</sup> South China Normal University, China   |      |
| <b>008_05</b> | <b>The Effect of Isotropic and Anisotropic Scattering in Drain Region of Ballistic</b>   | 1247 |

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|        | <b>Channel Diode</b>   |      |
|        | A. Abudukelimu <sup>a</sup> , K. Kakushima <sup>b</sup> , P. Ahmet <sup>a</sup> , M. Geni <sup>c</sup> , K. Tsutsui <sup>b</sup> , A. Nishiyama <sup>b</sup> , N. Sugii <sup>b</sup> , K. Natori <sup>a</sup> , T. Hat tori <sup>a</sup> , H. Iwai <sup>a</sup>                                  |      |
|        | <sup>a</sup> Frontier Research Center, Tokyo Institute of Technology, Japan; <sup>b</sup> Interdisciplinary Graduate School of Science and Engineering, Tokyo Institute of Technology, Japan   |      |
| P08_01 | <b>Interface states and nc-Si dots induced charging/discharging effects in floating gate MOS structures</b>  | 1250 |
|        | Guang-Yuan Liu, Zhong-Yuan Ma, Kun-Ji Chen, Zhong-Hui Fang, Xin-Ye Qian, Xiao-Fan Jiang, Xian-Gao Zhang, Xin-Fan Huang   |      |
|        | Nanjing University, China  |      |
| P08_02 | <b>Short-Range Interaction Affecting Transport Properties of Two-dimensional Electron Gas with Nearby Embedded Self-assembled GaSb/GaAs Type-II Quantum Dots</b>   | 1253 |
|        | Guodong Li, <sup>1,2</sup> Hong Yin, <sup>1,2</sup> Chao Jiang, <sup>1</sup>   |      |
|        | <sup>1</sup> National Center for Nanoscience and Technology, China; <sup>2</sup> Graduate School of the Chinese Academy of Sciences, China.  |      |
| P08_04 | <b>Carbon nanotube FETs decorated by gold nanoparticles: Electrical properties and mechanism</b>   | 1259 |
|        | Qinqin Wei <sup>1,2</sup> , Ao Guo <sup>1</sup> , Yang Chai <sup>3</sup> , Zhong Jin <sup>4</sup> , Yan Li <sup>4</sup> , Zujin Shi <sup>4</sup> , Philip C. H. Chan <sup>3</sup> , Yunyi Fu <sup>1</sup> , Ru Huang <sup>1</sup> , Xing Zhang <sup>1</sup>                                      |      |
|        | <sup>1</sup> Department of Microelectronics, Peking University, Beijing, China; <sup>2</sup> Shandong University of Technology, China; <sup>3</sup> Hong Kong University of Science and Technology, China; <sup>4</sup> College of Chemistry and Molecular Engineering, Peking University, China |      |
| P08_05 | <b>Current Analysis of Dual Quantum Dot Transistor based on Schrödinger Equation</b>   | 1262 |
|        | Chugo Fujihashi  |      |
|        | Polytechnic University, Japan  |      |
| P08_06 | <b>Pre-cycling with higher voltages for endurance improvement of silicon nanocrystal memory device</b>   | 1265 |
|        | Yong Wang <sup>1</sup> , Xiaonan Yang <sup>1</sup> , Qin Wang <sup>1</sup> , Zongliang Huo <sup>1</sup> , Manhong Zhang <sup>1</sup> , Bo Zhang <sup>2</sup> , Ming Liu <sup>1</sup> ,   |      |
|        | <sup>1</sup> Chinese Academy of Sciences, China; <sup>2</sup> Grace Semiconductor Manufacturing Corporation, China   |      |

## Organic semiconductor devices and technologies

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| I09_01<br><b>(Invited)</b> | <b>Compact Modeling of Organic Thin-Film Transistors</b><br>Iñiguez <sup>1</sup> , Benjamin; Pallarès, Josep <sup>1</sup> ; Marsal, Lluís F. <sup>1</sup> ; Castro-Carranza, Alejandra <sup>1</sup> ; Cerdeira, Antonio <sup>2</sup> ; Estrada <sup>2</sup> , Magali | 1268 |
|                            | <sup>1</sup> Universitat Rovira i Virgili, Spain; <sup>2</sup> Departamento de Ingeniería Eléctrica, CINVESTAV, México   |      |
| I09_02                     | <b>Stretchable Large-Area Electronics using Organic Transistor Integrated Circuits</b>   | 1272 |

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| <b>(Invited)</b> | Tsuyoshi Sekitani <sup>1</sup> , Koichi Ishida <sup>2</sup> , Makoto Takamiya <sup>2</sup> , Takayasu Sakurai <sup>2</sup> , and Takao Someya <sup>1</sup>   |      |
|                  | <sup>1</sup> Department of Electric and Electronic Engineering and Information systems, The University of Tokyo, Japan; <sup>2</sup> Institute of Industrial Science, The University of Tokyo, Japan.  |      |
| <b>I09_03</b>    | <b>Mechanism Investigation and Structure Design of Organic Solar Cells for Improved Energy Conversion Efficiency</b>   | 1276 |
| <b>(Invited)</b> | Chunfu Zhang <sup>1</sup> , Zhenhua Lin <sup>1</sup> , E.T. Kang <sup>2</sup> , Chunxiang Zhu <sup>1</sup> ,   |      |
|                  | <sup>1</sup> National University of Singapore, Singapore; <sup>2</sup> National University of Singapore, Singapore   |      |
| <b>O09_01</b>    | <b>Tuning the Threshold Voltage of Low Voltage Organic Thin Film Transistor using light illumination</b>   | 1280 |
|                  | Liwei Shang, Ming Liu, Zhuoyu Ji, Yingpin Chen & Hong Wang   |      |
|                  | Academy of Sciences, China   |      |
| <b>O09_02</b>    | <b>Threshold Voltage Control of Copper Phthalocyanine Based Organic Field-Effect Transistors with a Poly(N-vinylcarbazole) Buffer Layer</b>  | 1283 |
|                  | Ying Wang, Yunqi Liu, Yabin Song, Chong-an Di, Yanming Sun, Weiping Wu, and Gui Yu   |      |
|                  | Academy of Sciences, China   |      |
| <b>P09_01</b>    | <b>Optimization of the structure of bilayer organic solar cells based on light intensity distribution and quantity of effective excitons</b>   | 1286 |
|                  | Xi Xi <sup>a</sup> , Jiaqi Wu <sup>b</sup> , Wenjia Li <sup>b</sup> , Jingjia Ji <sup>c,d</sup> , Zhengrong Shi <sup>c,d</sup> , Guohua Li <sup>b,d</sup> ,  |      |
|                  | <sup>a</sup> School of Communication and Control Engineering, Jiangnan University, China; <sup>b</sup> School of Science, Jiangnan University, China; <sup>c</sup> Suntech Power Co., Ltd., China; <sup>d</sup> Jiangsu (Suntech) Institute for Photovoltaic Technology, China |      |
| <b>P09_02</b>    | <b>Charging characteristics of Sb nanocrystals embedded in copper phthalocyanine films for memory applications</b>   | 1289 |
|                  | Yue Huang <sup>1</sup> , Shi-Jin Ding <sup>1</sup> , Dietrich R.T. Zahn <sup>2</sup>   |      |
|                  | <sup>1</sup> Fudan University, Shanghai 200433, China; <sup>2</sup> Chemnitz University of Technology, Germany   |      |
| <b>P09_04</b>    | <b>Detecting the Interface State of Organic Thin-film Transistors Through Hysteresis Characteristics</b>   | 1295 |
|                  | Zhuoyu Ji, Lijuan Zhen, Liwei Shang, Ming Liu, Hong Wang, Xin Liu and Maixing Han  |      |
|                  | Chinese Academy of Sciences, China   |      |

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| <b>(Invited)</b> | Yee-Chia Yeo, Hock-Chun Chin, Xiao Gong, Huixin Guo, Xingui Zhang   |      |

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|               | National University of Singapore, Singapore  |      |
| <b>I10_02</b> | <b>High-k III-V MOSFETs Enabled by Atomic Layer Deposition</b>   | 1302 |
| (Invited)     | Peide D. Ye<br>Purdue University, U.S.A.   |      |
| <b>I10_03</b> | <b>GaN Smart Discrete Power Devices</b>  | 1303 |
| (Invited)     | Kevin J. Chen and Chunhua Zhou<br>Hong Kong University of Science and Technology, Hong Kong  |      |
| <b>I10_04</b> | <b>Submicron-channel InGaAs MISFET with epitaxially grown source</b>   | 1307 |
| (Invited)     | Yasuyuki Miyamoto, Hisahi Saito and Toru Kanazawa<br>Tokyo Institute of Technology, Japan  |      |
| <b>I10_05</b> | <b>Bonding and gap states at GaAs- oxide interfaces</b>  | 1311 |
| (Invited)     | John Robertson<br>Cambridge University, UK   |      |
| <b>I10_06</b> | <b>Highly Efficient GaN Power Transistors and Integrated Circuits with High Breakdown Voltages</b>   | 1315 |
| (Invited)     | Tsuyoshi Tanaka <sup>1</sup> , Tetsuzo Ueda <sup>1</sup> , and Daisuke Ueda <sup>2</sup><br><sup>1</sup> Semiconductor Device Research Center, Semiconductor Company, Panasonic Corporation, Japan; <sup>2</sup> Advanced Technology Research Laboratories, Panasonic Corporation, Japan |      |
| <b>I10_07</b> | <b>Compact Millimeter-wave Frequency Doublers using Slow Wave Structure in Balun</b>   | 1319 |
| (Invited)     | Yu-Ann Lai <sup>1</sup> , Chun-Nien Chen <sup>1</sup> , Shih-Han Hung <sup>1</sup> , Wei-Chih Chien <sup>1</sup> and Yeong-Her Wang <sup>1</sup><br><sup>1</sup> National Cheng-Kung University, Taiwan, China   |      |
| <b>I10_08</b> | <b>Linear Power Amplifier Architectures and Its Packaging Technologies for New Generation Smart Phone Applications</b>   | 1323 |
| (Invited)     | Gary (Guohao) Zhang<br>Skyworks Solutions, Inc., USA   |      |
| <b>I10_09</b> | <b>Linear Power Amplifiers and Transmitter Modules for Mobile Applications</b>   | 1327 |
| (Invited)     | Wen Chen <sup>1</sup> , Haitao Zhang <sup>1</sup> , Mike Cardullo <sup>1</sup> , Andy Forbes <sup>1</sup> , Ting Xiong <sup>2</sup> , Ray Pavio <sup>1</sup><br><sup>1</sup> TriQuint Semiconductor Inc., USA; <sup>2</sup> TriQuint Semiconductor Inc., China                           |      |
| <b>I10_10</b> | <b>THz Oscillators Using Resonant Tunneling Diodes</b>   | 1331 |
| (Invited)     | M. Asada and S. Suzuki<br>Tokyo Institute of Technology, Japan   |      |
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|               | Wei Huang , Shudan Zhang, and Juyan Xu<br>China Electronic Technology Group Corporation, China   |      |
| <b>O10_02</b> | <b>4H-SiC MESFET with a Novel MOS Gate Controlled Spacer Layer Structure</b>   | 1338 |
|               | Kun Song, Chang-Chun Chai, Hu-Jun Jia, Yin-Tang Yang<br>Xidian University, China   |      |
| <b>O10_03</b> | <b>GaN High Electron Mobility Transistors with Localized Mg Doping and Drain Metal Extension</b>   | 1341 |
|               | Gang Xie <sup>1,2</sup> , Bo Zhang <sup>2</sup> , Fred Y. Fu <sup>3</sup> and W.T.Ng <sup>1</sup><br><sup>1</sup> University of Toronto, Canada; <sup>2</sup> University of Electronic Science and Technology of China Chengdu, China; <sup>3</sup> Crosslight software Inc, Canada      |      |

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| <b>O10_04</b> | <b>Breakdown voltage enhancement in lateral AlGaN/GaN heterojunction FETs with multiple field plates</b>   | 1344 |
|               | Petru Andrei   |      |
|               | Florida State University, USA  |      |
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|               | Zhubin Shi, Lan Peng, Linjun Wang, Kaifeng Qin, Jiahua Min, Jijun Zhang, Xiaoyan Liang, Yiben Xia  |      |
|               | Shanghai University, China   |      |
| <b>P10_02</b> | <b>Impact of Electron Rebound from Drain on Drive Current in Nano-Scale InGaAs MOSFETs</b>   | 1350 |
|               | Hiroki I. Fujishiro, Hisanao Watanabe, Takahiro Homma and Shinsuke Hara  |      |
|               | Tokyo University of Science, Japan   |      |
| <b>P10_03</b> | <b>AlGaN/GaN Dual Gate MOS HFET for Power Device Applications</b>  | 1353 |
|               | Rumin Gong <sup>1</sup> , Jinyan Wang <sup>1</sup> , Shenghou Liu <sup>1</sup> , Zhihua Dong <sup>1</sup> , Cheng. P. Wen <sup>1</sup> , Min Yu <sup>1</sup> , Yong Cai <sup>2</sup> , Baoshun Zhang <sup>2</sup>  |      |
|               | <sup>1</sup> Peking University, China; <sup>2</sup> Suzhou Institute of Nano-tech and Nano-bionics, China  |      |
| <b>P10_04</b> | <b>Effect of field plate length on DC characteristics of high breakdown voltage GaN HEMTs for power switching application</b>  | 1356 |
|               | Minglan Zhang <sup>1,2</sup> , Xiaoliang Wang <sup>1</sup> , Mingzeng Peng <sup>3</sup> , Xinyu Liu <sup>3</sup> , Ru Wang <sup>2</sup>  |      |
|               | <sup>1</sup> Chinese Academy of Sciences, China; <sup>2</sup> Hebei University of Technology, China; <sup>3</sup> Chinese Academy of Sciences, China   |      |
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|               | <sup>1</sup> Institute of Microelectronics, Peking University, China; <sup>2</sup> School of Physics, Peking University, China   |      |
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|               | Yao Yin <sup>1</sup> , Ruihua Cao <sup>1</sup> , Peng Chen <sup>1</sup> , Qing Wan <sup>2</sup> , Lin Pu <sup>1</sup> , Yi Shi# <sup>1</sup> , Rong Zhang <sup>1</sup> , Youdou Zheng <sup>1</sup>   |      |
|               | <sup>1</sup> Nanjing University, China; <sup>2</sup> Hunan University, China   |      |
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|               | Xingsheng Tong <sup>1</sup> , Longyan Yuan <sup>2</sup> , Xiao Zou <sup>1,2</sup>  |      |
|               | <sup>1</sup> Jianghan University, China; <sup>2</sup> Wuhan University, China.   |      |
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|               | <sup>1</sup> Shan Dong University, China; <sup>2</sup> Institute of Microelectronics of Chinese Academy of Science, China  |      |

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|               | Hong Kong University of Science and Technology, Hong Kong.  |      |
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|                  | University of Balearic Islands, Spain  |      |
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|                  | <sup>1</sup> Center for Information Technology Renato Archer, Brazil; <sup>2</sup> Center for Semiconductor Components, Brazil   |      |
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|                  | <sup>1</sup> National Nano Device Laboratories, Taiwan, China; <sup>2</sup> National Tsing Hua University, Taiwan, China   |      |
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| <b>(Invited)</b> | Eric Stern <sup>1</sup> , Aleksandar Vacic <sup>2</sup> , Nitin K. Rajan <sup>2</sup> , Jason M. Criscione <sup>1</sup> , Jason Park <sup>1</sup> , Tarek M. Fahmy <sup>1,3</sup> , and Mark A. Reed <sup>1,4</sup>  |      |
|                  | <sup>1</sup> Yale University, School of Engineering and Applied Science, Departments of <sup>1</sup> Biomedical, <sup>2</sup> Electrical and <sup>3</sup> Chemical Engineering and <sup>4</sup> Applied Physics, USA |      |
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|                  | <sup>1</sup> University of Florida, USA; <sup>2</sup> Oakland University, USA  |      |
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|                  | Institute for Integrative Nanosciences, IFW Dresden, Germany.  |      |
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|               | <sup>1</sup> Department of Electrical Engineering, National Chi Nan University, Taiwan, China; <sup>2</sup> Department of Applied Materials and Optoelectronic Engineering, National Chi Nan University, Taiwan, China. |      |
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|               | <sup>1</sup> Peking University, China; <sup>2</sup> Shenzhen Graduate School of Peking University, China  |      |
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|               | Shanghai IC R&D Center, China   |      |
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|               | <sup>1</sup> Department of Microelectronics, Fudan University, China; <sup>2</sup> Department of Materials Science,Fudan University, Shanghai 200433, China   |      |
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|               | <sup>1</sup> Université de Valenciennes, France; <sup>2</sup> Fudan University, China   |      |
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|               | <sup>1</sup> Chang Gung University, Taiwan, China; <sup>2</sup> Chi Nan University  |      |
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|               | <sup>a</sup> Shenzhen Graduate School, Peking University, PRC; <sup>b</sup> InfoVision Optoelectronics (Kunshan) Co., Ltd, PRC   |      |
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|               | <sup>1</sup> Institute of Microelectronics, Peking University, China; <sup>2</sup> Shenzhen Graduate School, Peking University, China  |      |
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|               | <sup>1</sup> Peking University, China; <sup>2</sup> Georgia Institute of Technology, Atlanta   |      |
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|               | <sup>1</sup> Hong Kong University of Science and Technology, China; <sup>2</sup> Peking University, China  |      |
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|               | <sup>1</sup> Department of Microelectronics, Fudan University, China; <sup>2</sup> State Key Laboratory of Genetic Engineering, Fudan University, China                              |      |
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|               | <sup>a</sup> North University of China, National Key Laboratory of Science and Technology on Electronic Test and Measurement, China; <sup>b</sup> Key Laboratory of Instrumentation Science & Dynamic Measurement (North University of China), China; <sup>c</sup> The 13th Research Institute, CETC, China |      |
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|               | <sup>1</sup> University of Shanghai for Science and Technology, China; <sup>2</sup> Chinese Academy of Sciences, China  |      |
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|               | Lixia Lin <sup>1</sup> , Jiahe Chen <sup>1,2</sup> , Deren Yang <sup>1</sup>  |      |
|               | <sup>1</sup> Zhejiang University, China; <sup>2</sup> Technische Universität Dresden, Germany   |      |
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|               | Hailei Wu <sup>1</sup> , Guosheng Sun <sup>1</sup> , Guoguo Yan <sup>1</sup> , Lei Wang <sup>1</sup> , Wanshun Zhao <sup>1</sup> , Xingfang Liu <sup>1</sup> , Yiping Zeng <sup>1</sup> and Jialiwen <sup>2</sup>   |      |
|               | <sup>1</sup> Chinese Academy of Sciences, China; <sup>2</sup> China Electric Power Research Institute, China  |      |
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|               | Zhao <sup>1</sup> , Xingfang Liu <sup>1</sup> , Yiping Zeng <sup>1</sup> and Jialiang Wen <sup>2</sup>  |      |
|               | <sup>1</sup> Chinese Academy of Sciences, China; <sup>2</sup> China Electric Power Research Institute, China  |      |
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|               | <sup>1</sup> National University of Singapore, Singapore; <sup>2</sup> Institute of Microelectronics, Singapore   |      |
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|               | Nanjing University, China   |      |

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|                  | <sup>1</sup> National Chiao-Tung University, Taiwan, China; <sup>2</sup> I-Shou University, Taiwan, China; <sup>3</sup> Himax Technologies, Taiwan, China  |      |
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| <b>(Invited)</b> | Jordi Suñé <sup>1</sup> , Ermest Y. Wu <sup>2</sup> and S. Tous <sup>1</sup>   |      |
|                  | <sup>1</sup> Universitat Autònoma de Barcelona, SPAIN; <sup>2</sup> IBM Microelectronics Division, Essex Junction, VT , USA  |      |
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|                  | <sup>1</sup> Nanyang Technological University, Singapore; <sup>2</sup> Singapore Institute of Manufacturing Technology, Singapore  |      |
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|                  | <sup>1</sup> CitrusCom Semiconductor, China; <sup>2</sup> University of California, USA; <sup>3</sup> Tsinghua University, China; <sup>4</sup> Fairchild Semiconductor, USA                              |      |
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| <b>(Invited)</b> | F.Yan <sup>1</sup> , X.Ji <sup>1</sup> , Y.Liao <sup>1</sup> ,X.Cheng <sup>1</sup> ,X.Zhu <sup>1</sup> , Y.Shi <sup>1</sup> D.Zhang <sup>2</sup> , Q.Guo <sup>2</sup>                                    |      |
|                  | <sup>1</sup> Nanjing University, China; <sup>2</sup> Semiconductor Manufacturing International Corporation, China  |      |

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|                  | <sup>1</sup> Fudan University, Shanghai 200433, China; <sup>2</sup> A*STAR (Agency for Science, technology and Research), Singapore; <sup>3</sup> Nanyang Technological University, Singapore  |      |
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|                  | Southeast University, China  |      |
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|                  | Yue Zhang <sup>1</sup> , Miao Li <sup>2</sup> , Yan-Feng Li <sup>2</sup> , Xiao-Hua Ma <sup>3</sup> , Yan-Rong Cao <sup>4</sup> , Yue Hao <sup>1</sup>   |      |
|                  | <sup>1</sup> School of Microelectronics, Xidian University, China; <sup>2</sup> Accelicon Technologies, Inc, China; <sup>3</sup> School of Technical Physics, Xidian University, China; <sup>4</sup> School of Electronical & Machanical Engineering, Xidian University, China |      |
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|                  | <sup>1</sup> Xi'an University of Posts and Telecommunications, China; <sup>2</sup> Xidian University, China  |      |
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|                  | <sup>1</sup> Accelicon Technologies, Inc, CA; <sup>2</sup> Vanderbilt University, USA; <sup>3</sup> Chinese Academy of Science, China.   |      |
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|                  | <sup>1</sup> Peking University Shenzhen Graduate School, China; <sup>2</sup> Peking University, China; <sup>3</sup> Peking University Shenzhen SOC Key Laboratory, PKU HKUST Shenzhen Institute, IER Bldg., China  |      |
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|               | <sup>1</sup> Nanjing University, China; <sup>2</sup> SMIC, P. R. China  |      |
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|               | <sup>1</sup> Universitat Autònoma de Barcelona (Spain); <sup>2</sup> imec, Leuven (Belgium); <sup>3</sup> ASM Internation, Leuven (Belgium); <sup>4</sup> ASM International, Phoenix (USA)  |      |
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|               | Cai Xiaowu, Yan Beiping, Han Xiaoyong   |      |
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|               | <sup>1</sup> Xidian University, China; <sup>2</sup> Northwest Institute of Nuclear Technology, China  |      |
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|               | <sup>1</sup> Peking University Shenzhen Graduate School, China; <sup>2</sup> Peking University, China; <sup>3</sup> Peking University Shenzhen SOC Key Laboratory, PKU HKUST Shenzhen Institute, IER Bldg., China  |      |
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|               | Shen-Li Chen <sup>1</sup> , Tzung-Shian Wu <sup>1</sup> , Hung-Wei Chen <sup>1</sup> , Chun-Hsing Shih <sup>1</sup> , and Po-Ying Chen <sup>2</sup><br><sup>1</sup> National United University, Taiwan, China; <sup>2</sup> I-Shou University, Taiwan, China   |      |
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|        | <sup>1</sup> Harbin University of Science and Technology, China; <sup>2</sup> Jilin Institute of Chemical Technology, China                              |      |
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|        | Peking University, China   |      |

## Modeling and simulation

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|           | Nanyang Technological University, Singapore  |      |
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| (Invited) | S'ebastien Cliquennois <sup>1</sup> , Christophe Pr'emont <sup>2</sup>   |      |
|           | <sup>1</sup> ST-Ericsson, Sweden; <sup>2</sup> ST-Ericsson, France   |      |
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|           | Norwegian University of Science and Technology, Norway   |      |
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| (Invited) | M. Pourfath, V. Sverdlov, and S. Selberherr  |      |
|           | Institute for Microelectronics, TU Wien, Austria   |      |

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|                  | <sup>1</sup> Peking University, P. R. China; <sup>2</sup> PKU HKUST Shenzhen Institute, P.R.China; <sup>3</sup> Chinese Academy of Sciences, China   |      |
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| <b>(Invited)</b> | Yoshinari Kamakura <sup>1,2</sup> , Tomofumi Zushi <sup>3</sup> , Takanobu Watanabe <sup>3</sup> , Nobuya Mori <sup>1,2</sup> , and Kenji Taniguchi <sup>1</sup>   |      |
|                  | <sup>1</sup> Osaka University, Japan; <sup>2</sup> CREST, JST, Japan; <sup>3</sup> FWaseda University, Japan   |      |
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|                  | ProPlus Design Solutions Inc., USA   |      |
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|                  | <sup>a</sup> University of São Paulo, Brazil; <sup>b</sup> Imec, Belgium; <sup>c</sup> KU Leuven, Leuven, Belgium  |      |
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| <b>(Invited)</b> | Nobuya Mori <sup>1,2</sup> , Hideki Minari <sup>1,2</sup> , Genaddy Mil'nikov <sup>1,2</sup> , and Yoshinari Kamakura <sup>1,2</sup>   |      |
|                  | <sup>1</sup> Osaka University, Japan; <sup>2</sup> CREST, JST, Japan   |      |
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| <b>(Invited)</b> | Gino Giusi <sup>1</sup> , Giuseppe Iannaccone <sup>2</sup> , Debabrata Maji <sup>3</sup> , Felice Crupi <sup>1</sup>   |      |
|                  | <sup>1</sup> University of Calabria, Italy; <sup>2</sup> University of Pisa, Italy; <sup>3</sup> Indian Institute of Technology, India   |      |
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| <b>(Invited)</b> | Masato Senami <sup>1</sup> , Akitomo Tachibana <sup>1</sup>  |      |
|                  | <sup>1</sup> Kyoto University, Japan   |      |
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|                  | University of California, USA  |      |
| <b>I14_14</b>    | <b>TCAD Modeling Challenges for 22nm Node and beyond</b>   | 1778 |
| <b>(Invited)</b> | Jeff Wu  |      |
|                  | Taiwan Semiconductor Manufacturing Company (TSMC) Ltd., Taiwan, China  |      |
| <b>I14_15</b>    | <b>SelfHeating Effects in Analog Bulk and SOI CMOS Circuits</b>  | 1782 |
| <b>(Invited)</b> | Urmimala Roy, Enrico Sangiorgi, Claudio Fiegna   |      |
|                  | <sup>1</sup> University of Bologna and IUNET, Italy  |      |

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| <b>O14_02</b> | <b>A Proposal of Trapezoid Mesa Trench MOS Barrier Schottky Rectifier</b>   | 1789 |
|               | Weiyi Li, Guo-Ping Ru, Yu-Long Jiang, Gang Ruan   |      |
|               | Fudan University, China   |      |
| <b>O14_03</b> | <b>Transient effects of graded-channel partially depleted SOI <i>n</i>MOSFET</b>  | 1792 |
|               | Minghua Tang, Yongguang Xiao, Lianbao Zhang, Xiaolei Xu, Jun Zhang, Junxiong Tang   |      |
|               | Xiangtan University, China  |      |
| <b>O14_04</b> | <b>Subthreshold Swing Model for Asymmetric 3T Double Gate (DG) MOSFETs</b>  | 1796 |
|               | Pramod Kumar Tiwari, Sarvesh Dubey and S. Jit   |      |
|               | IT-BHU, India   |      |
| <b>O14_05</b> | <b>A novel automatic inductor model extraction methodology with ensured physical scalability</b>  | 1799 |
|               | Yang Tang <sup>1</sup> , Miao Li <sup>2</sup> , Yan Wang <sup>1</sup>   |      |
|               | <sup>1</sup> Tsinghua University, China; <sup>2</sup> Accelicon Technologies, Inc, China  |      |
| <b>O14_06</b> | <b>Processing Material Evaluation and Ultra-Wideband Modeling of Through-Strata-Via (TSV) in 3D Integrated Circuits and Systems</b>   | 1802 |
|               | Zheng Xu <sup>1</sup> , Adam Beece <sup>1</sup> , Dingyou Zhang <sup>1</sup> , Qianwen Chen <sup>1,2</sup> , Kenneth Rose <sup>1</sup> and James Jian-Qiang Lu <sup>1</sup>                                 |      |
|               | <sup>1</sup> Rensselaer Polytechnic Institute, USA; <sup>2</sup> Tsinghua University, China   |      |
| <b>O14_07</b> | <b>Compact Modeling Framework for Multigate SOI MOSFETs Based on Conformal Mapping Techniques</b>   | 1805 |
|               | Udit Monga <sup>1,2</sup> , Dag-Martin Nilsen <sup>1</sup> , Jasmin Aghassi <sup>2</sup> , Josef Sedlmeir <sup>2</sup> , Tor A. Fjeldly <sup>1</sup>  |      |
|               | <sup>1</sup> Norwegian University of Science and Technology, and University Graduate Center (UNIK), Norway; <sup>2</sup> Infineon Technologies AG, Germany  |      |
| <b>O14_08</b> | <b>An Improved Design of Si PNIN Tunneling Field Effect Transistor</b>  | 1808 |
|               | W. Cao, C. J. Yao, D. M. Huang, M.-F. Li  |      |
|               | Fudan University, China   |      |
| <b>O14_09</b> | <b>The electronic structure of graphene nanomesh</b>  | 1811 |
|               | Qihang Guo, Jinyu Zhang, Yu He, Jiahao Kang, He Qian, Yan Wang, and Zhiping Yu  |      |
|               | Tsinghua University, China  |      |
| <b>O14_10</b> | <b>A New Method for Series Resistance Extraction in Poly-Si Thin-Film Transistors</b>   | 1814 |
|               | Yan Zhou <sup>1</sup> , Mingxiang Wang <sup>1</sup> , Man Wong <sup>2</sup>   |      |
|               | <sup>1</sup> Soochow University, China; <sup>2</sup> Hong Kong Univ. of Science and Technology, Hong Kong   |      |
| <b>O14_11</b> | <b>Impact of Hump Effect on MOSFET Mismatch in the Sub-threshold Area for Low Power Analog Applications</b>   | 1817 |
|               | Yohan Joly <sup>1,2</sup> , Laurent Lopez <sup>1</sup> , Jean-Michel Portal <sup>2</sup> , Hassen Aziza <sup>2</sup> , Yannick Bert <sup>1</sup> , Franck Julien <sup>1</sup> , Pascal Fornara <sup>1</sup> |      |
|               | <sup>1</sup> STMicroelectronics, France; <sup>2</sup> IM2NP (UMR CNRS 6242), France   |      |
| <b>O14_12</b> | <b>Low Leakage Bulk Silicon Substrate Based SDOI FINFETs</b>  | 1820 |
|               | Jia Liu, Zhijong Luo, Haizhou Yin, Huilong Zhu, Hefei Wang, Feng Yuan   |      |
|               | Institute of Microelectronics, Chinese Academy of Sciences, P. R. China   |      |
| <b>O14_13</b> | <b>The Effects of Vacuum Spacer Transistors between High Performance and Low Stand-by Power Devices beyond 16nm</b>   | 1823 |

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|               | Jemin Park and Chenming Hu<br>Science University of California, Berkeley, USA   |      |
| <b>O14_14</b> | <b>Modeling of Terahertz Resonant Detection of MOS Field Effect Transistor Operating in All Regions under Optical Beating Mode</b>  | 1826 |
|               | Jingxuan Zhu <sup>1,3</sup> , Zhifeng Yan <sup>1,3</sup> , Yinglei Wang <sup>1,2,3</sup> , Xinnan Lin <sup>1,3</sup> , Jin He <sup>1,2,3</sup> , Wen Wu <sup>3</sup> , Zhiwei Liu <sup>3</sup> , Wenping Wang <sup>3</sup> , Yong Ma <sup>3</sup> , Juncheng Cao <sup>4</sup> |      |
|               | <sup>1</sup> Peking University Shenzhen Graduate School, , China; <sup>2</sup> TSRC, Peking University, China; <sup>3</sup> PKU HKUST Shenzhen Institute, China; <sup>4</sup> Shanghai Institute of Microsystems and Information Technology, Chinese Academy of Sciences      |      |
| <b>O14_15</b> | <b>A Compact Model of Resistive Switching Devices</b>   | 1829 |
|               | B. Chen <sup>1,2</sup> , Q.Y.Jun <sup>2</sup> , B. Gao <sup>2</sup> , F.F. Zhang <sup>2</sup> , K.L. Wei <sup>2</sup> , Y.S. Chen <sup>2</sup> , L.F. Liu <sup>2</sup> , X.Y. Liu <sup>2</sup> , J.F. Kang <sup>2</sup> , R.Q. Han <sup>2</sup>                               |      |
|               | <sup>1</sup> Peking University Shenzhen Graduate School, China; <sup>2</sup> Peking University, China,  |      |
| <b>O14_16</b> | <b>Theoretical Study on Geometry and Temperature Effects of Thermoelectric Properties of Si and Ge Nanowires</b>  | 1832 |
|               | Wen Huang, Chee Shin Koong, and Gengchiau Liang   |      |
|               | National University of Singapore, Singapore   |      |
| <b>O14_18</b> | <b>A 5V/200V SOI Device with a Vertically Linear Graded Drift Region</b>  | 1838 |
|               | Shao-Ming Yang <sup>1</sup> , Yin-Huang Lin <sup>2</sup> , Gene Sheu <sup>1</sup> , Jung-Ruey Tasi <sup>1</sup> , Shang-Hui Tu <sup>2</sup> , Yu-Lung Chin <sup>2</sup> , Jin-Shyong Jan <sup>2</sup> and Chia-Hao Lee <sup>2</sup>   |      |
|               | <sup>1</sup> Asia University, Taiwan, China; <sup>2</sup> Vanguard International Semiconductor Corp., Taiwan, China   |      |
| <b>P14_01</b> | <b>Electrode design of coplanar-grid diamond film detectors by finite element method</b>  | 1841 |
|               | Qingkai Zeng, Xiaoyu Pan, Mei Bi, Xingmao Yan, Linjun Wang, Jian Huang, Ke Tang, Jijun Zhang, Yiben Xia   |      |
|               | Shanghai University, China  |      |
| <b>P14_02</b> | <b>A Bias Dependent Body Resistance Model for Deep Submicron PDSOI Technology</b>   | 1844 |
|               | Jianhui Bu <sup>1</sup> , Jinshun Bi <sup>1</sup> , Mengxin Liu <sup>1</sup> , Haogang Cai <sup>2</sup> , Zhengsheng Han <sup>1</sup>   |      |
|               | <sup>1</sup> Institute of Microelectronics of Chinese Academy and Sciences, China <sup>2</sup> Columbia University, USA   |      |
| <b>P14_03</b> | <b>A Device-Physics-Basic SPICE Model for PDSOI CMOS SEU</b>  | 1847 |
|               | Zihan Fan, Jinshun Bi, Jiajun Luo, Zhengsheng Han   |      |
|               | The Institute of Microelectronics of Chinese Academy of Sciences, China   |      |
| <b>P14_04</b> | <b>A 2D Analytical Model of Bulk-silicon Triple RESURF Devices</b>  | 1850 |
|               | Tingting Hua <sup>1</sup> , Yufeng Guo <sup>1</sup> , Gene Sheu <sup>2</sup>  |      |
|               | <sup>1</sup> Nanjing University of Posts and Telecommunications,China; <sup>2</sup> Asia University, Taiwan, China  |      |
| <b>P14_05</b> | <b>Computational analysis of GaAs/AlGaAs deposition in MOCVD vertical rotating disk</b>   | 1853 |

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|               | <b>reactor</b>   |      |
|               | Rui Chen, Jianjun Li, Xuan Ya, Jun Deng, Jun Han, Shaojun Luo, Lingchun Gao, Guang-di Shen   |      |
|               | Beijing University of Technology, China  |      |
| <b>P14_06</b> | <b>A Modified GP Large-Signal Model for InGaP/GaAs HBT and Direct Optimization Extraction Methodology</b>  | 1856 |
|               | <sup>1</sup> Ying Zhang, <sup>2</sup> Miao Li, <sup>1</sup> Yuxia Shi, <sup>1</sup> Li Zhang and <sup>1</sup> Yan Wang   |      |
|               | <sup>1</sup> Tsinghua University, China; <sup>2</sup> Accelicon Technologies, Inc, China   |      |
| <b>P14_07</b> | <b>Simulation of Light Addressable Potentiometric Sensors based on MEDICI</b>  | 1859 |
|               | Yunfang Jia <sup>1</sup> , Lijun Ma <sup>1</sup> , Qiaoshan Chen <sup>1</sup> , Jiadai Liu <sup>1</sup> , Keli Xing <sup>2</sup> , Wencheng Niu <sup>1</sup>   |      |
|               | <sup>1</sup> Nankai University, P. R. China; <sup>2</sup> Tianjin Medical University, P. R. China  |      |
| <b>P14_08</b> | <b>Use of AlGaN Launcher in Terahertz GaN Gunn Diode</b>   | 1862 |
|               | Chunli Yu, Linan Yang, Qingyang Yao, Qi Liu, Xuhu Zhang  |      |
|               | Xidian University, China   |      |
| <b>P14_09</b> | <b>Modeling and Simulating for 3-D Micro-Manufacture Process</b>   | 1865 |
|               | Xu-Dongliang <sup>1</sup> , Zhang-Jian <sup>1</sup>  |      |
|               | <sup>1</sup> Hefei University of Technology , China  |      |
| <b>P14_10</b> | <b>Numerical simulation of 4H-SiC MESFETs with varied p-buffer layer thickness for microwave power device applications</b>   | 1868 |
|               | Xiao-chuan Deng <sup>1</sup> , Bo Zhang <sup>1</sup> , Yi Wang <sup>1</sup> , Zhao-ji Li <sup>1</sup>  |      |
|               | <sup>1</sup> University of Electronic Science and Technology of China, PR China  |      |
| <b>P14_11</b> | <b>A Complete Stress Enhancement Model Development and Verification Platform for 32nmTechnology and Beyond</b>   | 1871 |
|               | Yanfeng Li <sup>1</sup> , Nengyong Zhu <sup>1</sup> , Miao Li <sup>1</sup> , Yanjun Wu <sup>1</sup> , Qiang Chen <sup>1</sup> , Shuang Cai <sup>1</sup> Riko Radojcic <sup>2</sup> , Mark Nakamoto <sup>2</sup>  |      |
|               | <sup>1</sup> Accelicon Technologies, Inc, USA; <sup>2</sup> Qualcomm 5775 Morehouse Drive San Diego, USA   |      |
| <b>P14_12</b> | <b>An improved computationally efficient drain current model for double-gate MOSFETs</b>   | 1874 |
|               | Xingye Zhou <sup>1,2</sup> , Jian Zhang <sup>1</sup> , Zhize Zhou <sup>1</sup> , Lining Zhang <sup>1</sup> , Chenyue Ma <sup>1</sup> , Wen Wu <sup>3</sup> , Wei Zhao <sup>3</sup> , and Xing Zhang <sup>1</sup> ,   |      |
|               | <sup>1</sup> Peking University Shenzhen Graduate School, P. R. China; <sup>2</sup> Peking University , P. R. China; <sup>3</sup> PKU HKUST Shenzhen Institute, P. R. China   |      |
| <b>P14_13</b> | <b>Bandstructures of Unstrained and Strained Silicon Nanowire</b>  | 1877 |
|               | Lining Zhang <sup>1,2,3,4</sup> , Haijun Lou <sup>1</sup> , Zhiwei Liu <sup>2</sup> , Frank He <sup>1,2,3</sup> , and Mansun Chan <sup>4</sup>   |      |
|               | <sup>1</sup> Peking University Shenzhen Graduate School, China; <sup>2</sup> Peking University Shenzhen SOC Key Laboratory, China; <sup>3</sup> TSRC, IME, Peking University, China; <sup>4</sup> Hong Kong University of Science and Technology                       |      |
| <b>P14_14</b> | <b>A Potential-based Analytic Model for Monocrystalline Silicon Thin-film Transistors on Glass Substrates</b>  | 1880 |
|               | Shaodi Wang <sup>1,2</sup> , Lining Zhang <sup>2</sup> , Jian Zhang <sup>2</sup> , Wenping Wang <sup>2</sup> , Wen Wu <sup>2</sup> , Xukai Zhang <sup>1</sup> , Zhiwei Liu <sup>2</sup> , Wei Bian <sup>2</sup> , Frank He <sup>1,2</sup> and Mansun Chan <sup>3</sup> |      |
|               | <sup>1</sup> PekingUniversity Shenzhen Graduate School, P. R. China; <sup>2</sup> Peking University Shenzhen SOC Key Laboratory, P. R. China; <sup>3</sup> Hong Kong University of Science and Technology, Hong Kong   |      |

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| <b>P14_15</b> | <b>An Analog CMOS Pulse Coupled Neural Network for Image Segmentation</b>  | 1883 |
|               | Ying Xiong <sup>1</sup> , Wei-Hua Han, Kai Zhao, Yan-Bo Zhang, Fu-Hua Yang   |      |
|               | <sup>1</sup> Chinese Academy of Science, China   |      |
| <b>P14_16</b> | <b>An Accurate Compact Model with Skin and Proximity Effects for High Coupling-Coefficient Transformers</b>  | 1886 |
|               | Hongda Zheng, Dajie Zeng, Dongxu Yang, Li Zhang, and Zhiping Yu  |      |
|               | Tsinghua University, China   |      |
| <b>P14_17</b> | <b>A Novel Hybrid-Anode AlGaN/GaN Field-Effect Rectifier with Low Operation Voltage</b>  | 1889 |
|               | Zhigang Wang, Bo Zhang, Wanjun Chen, Zhaoji Li   |      |
|               | University of Electronic Science and Technology of China, China  |      |
| <b>P14_18</b> | <b>OPNEC-Sim: An Efficient Simulation Tool for Network-on-Chip Communication and Energy Performance Analysis</b>   | 1892 |
|               | Cai Jueping <sup>1</sup> , Huang Gang <sup>1</sup> , Wang Shaoli <sup>2</sup> , Yao Lei <sup>2</sup> , Li Zan <sup>2</sup> and Hao Yue <sup>1</sup>  |      |
|               | <sup>1</sup> Wide Bandgap Semiconductor Technology Disciplines State Key Laboratory, Xidian University, China; <sup>2</sup> State Key Laboratory of Integrated Services Networks, Xidian University, China |      |
| <b>P14_19</b> | <b>Effective Behavioral Models for <math>\Sigma\Delta</math> Fractional-N Frequency Synthesize Phase Noise Prediction</b>  | 1895 |
|               | Wenfeng Lou, Xiaozhou Yan, Zhiqing Geng, <sup>(2)</sup> Zhihua Wang, <sup>(1)</sup> Nanjian Wu   |      |
|               | <sup>(1)</sup> Chinese Academy of Sciences, P. R. China; <sup>(2)</sup> Tsinghua University, China   |      |
| <b>P14_20</b> | <b>Design and Simulation of a High Resolution Ultrasonic Micro-Transducer Derived by LiNbO<sub>3</sub></b>   | 1898 |
|               | Jin-ying Zhang <sup>1,2</sup> , Xin-ming Ji <sup>1</sup> , Wei-jiang Xu <sup>2</sup> , Julien Carlier <sup>2</sup> , Bertrand Nongaillard <sup>2</sup> , Yi-ping Huang <sup>1</sup>                        |      |
|               | <sup>1</sup> Fudan University, P. R. China; <sup>2</sup> Université de Valenciennes et du Hainaut Cambrésis, France  |      |
| <b>P14_21</b> | <b>Performance Optimization of n-MOSFETs Using Asymmetric Interfacial Oxide layer</b>  | 1901 |
|               | Weize Yu , Zhijiong Luo, Huilong Zhu, Qingqing Liang, and Haizhou Yin  |      |
|               | Institute of Microelectronics of Chinese Academy of Sciences, P. R. China  |      |
| <b>P14_22</b> | <b>Current Modeling and Simulation of Dual-Material Surrounding-Gate MOSFET with Asymmetric Halo</b>   | 1904 |
|               | Zun-Chao L <sup>i</sup> , Jin-Peng Xu, and Lin-Lin Liu   |      |
|               | Xi'an Jiaotong University, China   |      |
| <b>P14_23</b> | <b>LPCVD Process Simulation Based On Monte Carlo Method</b>  | 1907 |
|               | Jian-Yang Dai, Zai-Fa Zhou, Qing-An Huang, Wei-Hua Li  |      |
|               | Southeast University, China  |      |
| <b>P14_24</b> | <b>A New Extraction Method for Source/Drain Resistance in MOSFETs</b>  | 1910 |
|               | Yang-Hua Chang, Yao-Jen Liu  |      |
|               | National Yunlin University of Science & Technology, Taiwan, China  |      |
| <b>P14_25</b> | <b>Research on Modeling for the Pattern Library of Interconnect parasitic capacitances in VLSI</b>   | 1913 |
|               | Hui Qu <sup>1</sup> , Xiaoyu Xu <sup>1</sup> , and Zhuoxiang Ren <sup>2</sup>  |      |
|               | <sup>1</sup> Chinese Academy of Sciences,China; <sup>2</sup> UPMC University of Paris 6, France  |      |

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| <b>P14_26</b> | <b>A High Speed Low Power Interface for Inter-die Communication</b>   | 1916 |
|               | Siliang Hua <sup>1</sup> , Qi Wang <sup>1,2</sup> , Hao Yan <sup>1,2</sup> , Donghui Wang <sup>1</sup> , Chaohuan Hou <sup>1</sup>  |      |
|               | <sup>1</sup> Institute of Acoustics, Chinese Academy of Sciences, China; <sup>2</sup> Graduate University of Chinese Academy of Sciences, China   |      |
| <b>P14_27</b> | <b>A Threshold Voltage Model for the Surrounding-Gate MOSFETs</b>   | 1919 |
|               | Guanghui Mei, Guangxi Hu, Peicheng Li, Jinglun Gu, Ran Liu and Tingao Tang  |      |
|               | Fudan University, China   |      |
| <b>P14_28</b> | <b>An Analytic Threshold Voltage Model for the Double-Gate Schottky-Barrier Source/Drain MOSFETs</b>  | 1922 |
|               | Peicheng Li, Guangxi Hu, Guanghui Mei, Ran Liu, Yi Jiang and Tingao Tang  |      |
|               | Fudan University, China   |      |
| <b>P14_29</b> | <b>A Simplified Simulation Model for CMOS Integrated Hall Devices Working at Low Magnetic Field Circumstance</b>  | 1925 |
|               | Yue Xu, Fei-Fei Zhao  |      |
|               | Nanjing University of Posts and Telecommunications, China   |      |
| <b>P14_30</b> | <b>Design and Simulation of the vertical pnp transistor on SOI</b>  | 1928 |
|               | JieXin Luo <sup>1</sup> , Jing Chen, JianHua Zhou, QingQing Wu, XiaoLu Huang, Xi Wang   |      |
|               | <sup>1</sup> Shanghai Institute of Microsystem and Information Technology, Chinese Academy of Sciences, China   |      |
| <b>P14_31</b> | <b>Analytical models of the transition layer in HEMTs on silicon substrate for device simulation</b>  | 1931 |
|               | Petru Andrei  |      |
|               | Florida State University, USA   |      |
| <b>P14_32</b> | <b>Improved mobility model of MOSFETs for device simulation</b>   | 1934 |
|               | Wu Qingqing, Chen Jing, Wang Xi   |      |
|               | Shanghai Institute of Microsystem and Information Technology, CAS, China  |      |
| <b>P14_33</b> | <b>On Dynamic Behavior of Triangular Shaped Cantilevers in MEMS Sensors: Effect of Curvature</b>  | 1937 |
|               | Gui-Ming Zhang <sup>1</sup> , Li-Bo Zhao <sup>2,1</sup> , En-Ze Huang <sup>1</sup> , Guo-Ying Yuan <sup>1</sup> , Yong Li <sup>2</sup> , Zhi-Gang Liu <sup>3</sup> and Zhuang-De Jiang <sup>1</sup> |      |
|               | <sup>1</sup> Xi'an Jiaotong University, China; <sup>2</sup> Tsinghua University, China <sup>3</sup> Xi'an Jiaotong University, China  |      |
| <b>P14_34</b> | <b>Modeling Low Frequency Noise in PDSOI MOSFETs for Analog and RF Applications</b>   | 1940 |
|               | S. Sirohi <sup>1</sup> and S. Khandelwal <sup>1</sup>   |      |
|               | <sup>1</sup> IBM Semiconductor Research & Development Centre, India   |      |
| <b>P14_35</b> | <b>Simple Approach for Statistical Modeling of Process Impacts on CMOS Device Variations in VLSI Applications</b>   | 1943 |
|               | Meng Li, Qingqing Liang, Huicai Zhong, and Huilong Zhu  |      |
|               | Institute of MicroElectronics of Chinese Academy of Sciences, China,  |      |
| <b>P14_36</b> | <b>Modeling the Parasitic Bipolar Device in the 40nm PD SOI NMOS Device Considering the Floating Body Effect</b>  | 1946 |
|               | C. H. Chen, J. B. Kuo, D. Chen, and C. S. Yeh   |      |
|               | National Taiwan University, Taiwan, China; UMC, Taiwan, China   |      |

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| <b>P14_37</b> | <b>Evaluation the Layout Dependences on Strained 22nm NMOSFETs</b>  | 1949 |
|               | Jieyu Qin <sup>1,2</sup> , Gang Du <sup>2</sup> , Ruqi Han <sup>2</sup> , Xiaoyan Liu <sup>2</sup>  |      |
|               | <sup>1</sup> Shenzhen Graduate School, Peking University, China; <sup>2</sup> Institute of Microelectronics, Peking University, China                       |      |
| <b>P14_38</b> | <b>Study of 20nm bulk FINFET by Using 3D full band Monte Carlo Method with Effective Potential Quantum Correction</b>                                       | 1952 |
|               | Gang Du <sup>1</sup> , Wei Zhang <sup>2</sup> , Juncheng Wang <sup>1</sup> , Tiao Lu <sup>2</sup> , Pingwen Zhang <sup>2</sup> , Xiaoyan Liu <sup>1</sup>   |      |
|               | <sup>1</sup> Institute of Microelectronics, Peking University, China; <sup>2</sup> School of Mathematical Sciences, LMAM and CAPT, Peking University, China |      |
| <b>P14_39</b> | <b>Collision Based Capacitive Vibration Energy Harvesting</b>   | 1955 |
|               | Ling Bu, Xiaoming Wu, Litian Liu  |      |
|               | Tsinghua University, China  |      |
| <b>P14_40</b> | <b>Predictive Modeling of Capacitance and Resistance in Gate-all-around Cylindrical Nanowire MOSFETs for Parasitic Design Optimization</b>                  | 1958 |
|               | Qiumin Xu, Jibin Zou, Jieyin Luo, Runsheng Wang, Ru Huang   |      |
|               | Peking University , China   |      |

### Packaging and testing technology

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| <b>P15_01</b> | <b>A Vacuum/airtight Package with Multifunctional LTCC Substrate and Integrated Pirani Vacuum Gauge for 3D SIP Integration Applications</b>  | 1961 |
|               | Min Miao <sup>1,2</sup> , Hua Gan <sup>2,3</sup> , Yufeng Jin <sup>2</sup> , Zhensong Li <sup>1</sup>  |      |
|               | <sup>1</sup> Beijing Information Science and Technology University, China; <sup>2</sup> Peking University, China;<br><sup>3</sup> Shenzhen Graduate School of Peking University, China |      |
| <b>P15_02</b> | <b>Study on The Accelerated Soakage Testing during The Reliability Evaluation of Plastic Package</b>   | 1964 |
|               | Qian Min <sup>1</sup> , Yang Cuijun <sup>1</sup> , Yuan Hua <sup>1,2</sup> , Cao Yunpeng <sup>1</sup>  |      |
|               | Suzhou University, China   |      |
| <b>P15_04</b> | <b>Design and Implementation of a Differential Power Analysis System for Cryptographic Devices</b>   | 1967 |
|               | Cong Chen, Xiangyu Li, Liji Wu, Xiangmin Zhang   |      |
|               | Institute of Microelectronics of Tsinghua University, China  |      |
| <b>P15_05</b> | <b>The implementation of the global scheduling strategy</b>  | 1970 |
|               | Jinyi Zhang <sup>1,3</sup> , Wanlin Cai <sup>2</sup> , Chunhua Wang <sup>3</sup>   |      |
|               | <sup>1-3</sup> Shanghai University, China  |      |
| <b>P15_06</b> | <b>Improved Delay Fault Coverage in SoC Using Controllable Multi-Scan-Enable</b>   | 1973 |
|               | Jin-yi ZHANG <sup>1,3</sup> , Xu-hui HUANG <sup>2</sup> , Wan-lin CAI <sup>2</sup> , Han-yi WENG1,3  |      |
|               | <sup>1-3</sup> Shanghai University, China  |      |
| <b>P15_07</b> | <b>Automated Test Bitstream Generation for an SOI-Based FPGA</b>   | 1976 |
|               | Yan Li, Stanley L. Chen, Liang Chen, Qianli Zhang, Ming Li   |      |
|               | Chinese Academy of Sciences, China   |      |
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| <b>P18_12</b> | <b>An Energy Efficient Cluster Based node scheduling Protocol for Wireless Sensor Networks</b>  | 2053 |
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|               | <sup>1</sup> Institute of Semiconductors , CAS, China <sup>2</sup> Peking University, China   |      |

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